



#3/Amdt A  
7/16/03  
C. Poi

PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Chao-Hu Liang, Examiner: MAI, ANH D  
5 Chih-Hung Chen,  
Yu-Shan Tai,  
Po-Lun Cheng

Filing Date: 03/25/2002 Art Unit: 2814  
Serial No.: 10/063,128 Docket No.: NAUP0385USA

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Title: METHOD OF FORMING A POLYSILICON LAYER

To: Commissioner for Patents  
P.O. Box 1450  
15 Alexandria, VA 22313-1450

Subject: Response to the Office Action dated 04/22/2003

20 Dear Sir/Madam:

INTRODUCTORY COMMENTS

In response to the Office Action identified above,  
25 the above-identified application is to be amended as  
indicated in the following sections. Consideration of  
all amendments is politely requested.

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JUL-9 2003  
TECHNOLOGY CENTER 2800